

Appl. No. 10/502,490
Amdt. Dated October 30, 2006
Reply to Office Action of June 30, 2006

Attorney Docket No. 81864.0039
Customer No.: 26021

Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

Listing of Claims:

1. (Currently amended) A high frequency magnetic thin film comprising:
a first layer comprising a T-L composition (here, T is Fe or FeCo, L is only C);
and
a second layer comprising a Co-based amorphous alloy arranged on either of
the surfaces of said first layer,
wherein said first layer has a bcc structure.

2. (Currently amended) A high frequency magnetic thin film ~~according to claim 1, wherein~~ comprising:
a first layer comprising a T-L composition (T is Fe or FeCo, L is only C); and
a second layer comprising a Co-based amorphous alloy arranged on either of
the surfaces of said first layer, wherein
a plurality of said first layers and ~~a plurality of~~ one or more said second
layers are laminated to form a multilayer film structure.

3. (Original) A high frequency magnetic thin film according to claim 1 or 2,
wherein:
the real part (μ') of the complex permeability at 1 GHz is 400 or more,
the quality factor Q (μ'/μ'') is 4 or more, and
the saturation magnetization is 14 kG (1.4 T) or more.

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4. (Previously Presented) A high frequency magnetic thin film according to claim 1 or 2, wherein:

when T1 denotes the thickness of said first layer and T2 denotes the thickness of said second layer, T1 falls within the range from 3 to 70 nm and T1/T2 falls within the range from 0.15 to 3.50.

5. (Original) A high frequency magnetic thin film according to claim 1 or 2, wherein:

the real part (μ') of the complex permeability at 1 GHz is 500 or more,
the quality factor Q (μ'/μ'') is 10 or more, and
the saturation magnetization is 14 kG (1.4 T) or more.

6. (Original) A high frequency magnetic thin film according to claim 5, wherein:

when T1 denotes the thickness of said first layer and T2 denotes the thickness of said second layer, the thickness of said first layer T1 falls within the range from 0.5 to 3.0 nm and T1/T2 falls within the range from 0.8 to 3.0.

7. (Previously Presented) A high frequency magnetic thin film according to claim 1 or 2, wherein:

said second layer is mainly composed of Co, and comprises at least one additional element selected from the group consisting of B, C, Si, Ti, V, Cr, Mn, Fe, Ni, Y, Zr, Nb, Mo, Hf, Ta and W.

8. (Previously Presented) A high frequency magnetic thin film according to claim 1 or 2, wherein:

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said second layer is selected from the group consisting of CoZr, CoHf, CoNb, CoMo, CoZrNb, CoZrTa, CoFeZr, CoFeNb, CoTiNb, CoZrMo, CoFeB, CoZrNbMo, CoZrMoNi, CoFeZrB, CoFeSiB and CoZrCrMo.

9. (Previously Presented) A high frequency magnetic thin film according to claim 1 or 2, wherein:

the concentration of the element L contained in said first layer falls within the range from 2 to 20 at%.

10. (Previously Presented) A composite magnetic thin film, comprising:

a first layer which is mainly composed of Fe or FeCo and only C, with the saturation magnetization of 16 kG (1.6 T) or more by itself, and said first layer is constituted with a columnar structure of 1.4 or less aspect ratio or an amorphous structure, and

a second layer which is mainly composed of Co, having the properties by itself that the permeability is 1,000 or more (the measurement frequency: 10 MHz), the saturation magnetization is 10 kG (1.0 T) or more, and the resistivity is 100 $\mu\Omega$ cm or more, wherein:

said first layer and said second layer are alternately laminated.

11. (Previously Presented) A magnetic device comprising a high frequency magnetic thin film, wherein:

said high frequency magnetic thin film is a multilayer film wherein a first layer comprising a T-L composition (here, T is Fe or FeCo, L is only C) and a second layer comprising a Co-based amorphous alloy arranged on either of the surfaces of said first layer are alternately laminated.

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12. (Original) A magnetic device according to claim 11, wherein:
said magnetic device comprises said high frequency magnetic thin films
arranged to face each other so as to sandwich a coil.

13. (Original) A magnetic device according to claim 12, wherein said
magnetic device is an inductor or a transformer.

14. (Original) A magnetic device according to claim 12, wherein:
said magnetic device is an inductor used in a monolithic microwave
integrated circuit.

15-17. (Cancelled).

18. (New) A magnetic device according to claim 11, wherein:
said first layer has a bcc structure.

19. (New) A high frequency magnetic thin film according to claim 1,
wherein:

a plurality of said first layers and a plurality of said second layers are
laminated to form a multilayer film structure.